

L Number	Hits	Search Text	DB	Time stamp
1	8	((("4691662") or ("5292370") or ("5908319") or ("5844195") or ("5834371") or ("6182602") or ("5989345") or ("6170428")).PN.	USPAT; US-PGPUB	2003/11/18 10:59
2	2	wo-9744141-\$.did.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/11/18 11:01
3	2	jp-01272769-\$.did.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/11/18 11:03
4	160	(laermer near franz).in.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/11/18 11:10
5	89	(schilp near andreas).in.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/11/18 11:10
6	2	((schilp near andreas).in.) not ((laermer near franz).in.)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/11/18 11:10
7	1232	156/345.48,345.36,345.35.ccls. or 118/723i,723me,723ir,723er.ccls.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/11/18 12:53
8	36	(156/345.48,345.36,345.35.ccls. or 118/723i,723me,723ir,723er.ccls.) and (directional adj coupler)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/11/18 13:10
9	11	((156/345.48,345.36,345.35.ccls. or 118/723i,723me,723ir,723er.ccls.) and (directional adj coupler)) and water	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/11/18 13:17
10	10730	"78" and (water same load)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/11/18 13:18
11	15	(156/345.48,345.36,345.35.ccls. or 118/723i,723me,723ir,723er.ccls.) and (water same load)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/11/18 13:18
-	0	ep-0822584-\$.did.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/05/20 16:13
-	0	ep-00822584-\$.did.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/05/20 16:13

-	2	ep-822584-\$.did.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/05/20 16:13
-	1	6261962.pn.	USPAT; US-PGPUB	2003/05/20 16:17
-	18	("4533430" "4599135" "4635090" "4707218" "4784720" "4795529" "4832788" "4855017" "4985114" "5068202" "5074955" "5079178" "5368685" "5474650" "5478437" "5501893" "5605600" "6051503").PN.	USPAT	2003/05/20 16:17
-	87837	(deposition or deposit or deposited or depositing) same (etch or etched or etching)	USPAT; US-PGPUB	2003/05/20 16:54
-	37917	((deposition or deposit or deposited or depositing) same (etch or etched or etching)) and plasma	USPAT; US-PGPUB	2003/05/20 16:51
-	296459	156/345.\$ ccls. or 118/\$ ccls. or 204/\$ ccls. or 315/\$ ccls. or 438/\$ ccls. or 427/\$ ccls. or 216/\$ ccls. or 134/\$ ccls.	USPAT; US-PGPUB	2003/05/20 16:53
-	23775	((deposition or deposit or deposited or depositing) same (etch or etched or etching)) and plasma) and (156/345.\$ ccls. or 118/\$ ccls. or 204/\$ ccls. or 315/\$ ccls. or 438/\$ ccls. or 427/\$ ccls. or 216/\$ ccls. or 134/\$ ccls.)	USPAT; US-PGPUB	2003/05/20 16:53
-	6328	((deposition or deposit or deposited or depositing) same (etch or etched or etching)) and plasma) and (156/345.\$ ccls. or 118/\$ ccls. or 204/\$ ccls. or 315/\$ ccls. or 438/\$ ccls. or 427/\$ ccls. or 216/\$ ccls. or 134/\$ ccls.)) and ((deposition or deposit or deposited or depositing) same (etch or etched or etching)).ab,clm.	USPAT; US-PGPUB	2003/05/20 16:54
-	5037	((deposition or deposit or deposited or depositing) same (etch or etched or etching)) and plasma) and (156/345.\$ ccls. or 118/\$ ccls. or 204/\$ ccls. or 315/\$ ccls. or 438/\$ ccls. or 427/\$ ccls. or 216/\$ ccls. or 134/\$ ccls.)) and ((deposition or deposit or deposited or depositing) same (etch or etched or etching)).ab,clm.) and metal	USPAT; US-PGPUB	2003/05/20 16:54
-	422	((deposition or deposit or deposited or depositing) same (etch or etched or etching)) and plasma) and (156/345.\$ ccls. or 118/\$ ccls. or 204/\$ ccls. or 315/\$ ccls. or 438/\$ ccls. or 427/\$ ccls. or 216/\$ ccls. or 134/\$ ccls.)) and ((deposition or deposit or deposited or depositing) same (etch or etched or etching)).ab,clm.) and metal) and (inductive or inductively)	USPAT; US-PGPUB	2003/05/20 16:55
-	305	((deposition or deposit or deposited or depositing) same (etch or etched or etching)) and plasma) and (156/345.\$ ccls. or 118/\$ ccls. or 204/\$ ccls. or 315/\$ ccls. or 438/\$ ccls. or 427/\$ ccls. or 216/\$ ccls. or 134/\$ ccls.)) and ((deposition or deposit or deposited or depositing) same (etch or etched or etching)).ab,clm.) and metal) and ((inductive or inductively) near3 (plasma or discharge))	USPAT; US-PGPUB	2003/05/20 17:00
-	0	156/345/\$ ccls.	USPAT; US-PGPUB	2003/05/20 17:00
-	3577	156/345.\$ ccls.	USPAT; US-PGPUB	2003/05/20 17:00
-	1482	156/345.\$ ccls. and (clean or cleaning)	USPAT; US-PGPUB	2003/05/20 17:01
-	243	(156/345.\$ ccls. and (clean or cleaning)) and remote	USPAT; US-PGPUB	2003/05/20 17:01